



Docket No.: 8733.378.00-US
(PATENT)

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Election
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of:
Myoung-Su YANG

Application No.: 09/748,871

Group Art Unit: 2812

Filed: December 28, 2000

Examiner: R. E. Pompey

For: METHOD OF FORMING A
POLYCRYSTALLINE SILICON LAYER

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
Washington, DC 20231

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed August 27, 2002, Applicant hereby elects claims Group I, claims 1-12, for continued examination.

Should the Examiner deem that a telephone conference would further expedite the prosecution of this application, the Examiner is invited to call the undersigned at (202) 624-1200.


Applicant hereby authorizes the Commissioner of Patents to charges any fees necessary to complete this filing, including any fees required under 37 C.F.R. §1.136 for any necessary Extension of Time to make the filing of the attached documents timely, or credit any overpayment in fees, to Deposit Account No. 50-0911. Further, if these papers are not

considered timely filed, then a petition is hereby made under 37 C.F.R. §1.136 for the necessary extension of time.

Dated: September 24, 2002

Respectfully submitted,

MCKENNA LONG & ALDRIDGE, LLP

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